MEC from Uyemura

The Roadmap for High Density & Ultra High Density Circuits



7970 11423380 9040

137553558.0%

386.4Å⁰³

4374:58 382,48 382,48 Uyemura and MEC have a technology partnership that's rock-solid - and generations-long.

> This partnership is powerfully beneficial to both. Equally important, it benefits our valued customers, who have at their disposal the research, development, and service resources of both companies in creating innovative solutions and strategies to generate and maintain a competitive advantage.

This is Uyemura's most comprehensive brochure of MEC products in a decade.

For greater details on MEC processes and answers to your questions contact your Uyemura representative, our US headquarters, or our US Tech Center. Phone numbers for both are on the back cover.

Or, use the contact form located here: uyemura.com/contactus.htm

MEC from Uyemura IC Substrate Process Chart



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Copper surface topography created by MEC processes from Uyemura



超粗化系 密着向上処理

Super-roughening type adhesion enhancement

Optimal, application-based copper surface topographies that improve product reliability.

PKG基板ロードマップとメックの技術 Line Width Roadmap vs. MEC's Technology



前処理 Pre-treatment

クブライト

CA-5330A, CA-5340

銅表面超粗化剤メックエッチボンドCZの専用前処理剤です。CZの粗化能力 を阻害する物質(例えば、指紋、酸化物汚れ、ドライフィルムの接着剤等)を 非常に軽微なエッチングによって、効率よく除去します。メックエッチボンドの パフォーマンスを最大限に引き出し、最終製品の信頼性向上を図ります。 CA-5330A is a pre-treatment developed for the copper surface super-roughening agent MECetchBOND CZ. It effectively removes contaminants (fingerprints, oxide contamination, and dry film adhesives) that obstruct CZ roughening performance through very gentle etching. It maximizes MECetchBOND performance and improves the reliability of finished products.

- 銅表面の粗化

メックエッチボン

CZ-8100, CZ-8101, CZ-8201

銅表面の超粗化を実現した有機酸系マイクロエッチング剤です。銅表面の 独特の凹凸形状により、樹脂との高い密着性を実現します。ビルドアップ樹 脂積層前、ドライフィルムラミネート前、ソルダーレジスト塗布前、穴埋め樹 脂前など、高い密着性を要求される場合の銅表面粗化剤として幅広くご使 用いただけます。 This series consists of organic acid based microetching agents that carry out ultrafine roughening for copper surfaces.

The unique uneven topography of the copper surface enhances adhesion with resins. The agents can be widely used as copper surface roughening agents when a high level of adhesion is required, such as pre-treatment of lamination for build-up boards, pre-treatment of dry film lamination, pre-treatment solder mask printing, and pre-treatment of hole plugging.



防錆効果/化学密着性向上 Anti-tarnish effect, Improved chemical adhesior



CL-8300, CL-8301

メックエッチボンドCZ-8100シリーズにより粗化じた 郵表面を酸化から保護 すると共に、高Tg材料との密着性を向上させる有機皮膜を形成します。また、 CL-8301はFR-4材料に対しても高い密着性を発揮します。 メックエッチボンドCZ-8100シリーズと合わせてご使用ください。 In addition to protecting copper surfaces roughened by the MECetchBOND CZ-8100 series from oxidation, this series also creates an organic film that improves adhesion with high Tg materials. CL-8301 also demonstrates a high level of adhesion with FR-4 materials.

Use this series in combination with the MECetchBOND CZ-8100 series.

高周波基板向け 密着向上処理

Adhesion enhancement for high-frequency substrates

High Frequency Roadmap vs. MEC's Technology

Adhesion-enhancing process developed as a conductor surface treatment for high-frequency PCBs.



GT process

従来、表面粗化による密着性向上処理が使用されてきました が、高周波領域においては導体の表面凹凸による伝送損失の 問題があります。メックフラットボンドGTプロセスはエッチン グや表面粗化を伴わないため、高周波領域において伝送損 失を最小限に抑えることができます。また、高周波基板に使用 される低誘電率材料に対して優れた密着性を発揮します。



Conventionally, surface roughening has been used to improve adhesion, but this led to transmission loss due to the uneven surface of conductors in the high frequency range. The MEC GT process can minimize loss in the high frequency range, since it does not involve etching or surface roughening. It also exhibits excellent adhesion to the low dielectric constant materials used in high-frequency PCBs.



Before treatment



After GT process





Solutions and processes that meet customers' specifications.



圧延銅粗化処理

Chemicals for rolled copper

Uniform topographies for rolled copper foil surfaces.

UT series

電解銅/圧延銅に均一で同様な表面粗化を形成し、樹脂との 密着力を高めることができます。伝送損失への影響が小さ い為、高周波FPC用途としても期待されております。 Regardless of the type of copper foil, it can enhance mechanical adhesion strength between resin and copper by producing unique, uniform copper surface topography. UT series processes have a minimal effect on transmission loss, and are expected to be used for high-frequency FPC applications.



密着性

UT-4100はドライフィルム、UT-4120はソルダーレジストの密着向上 UT-4100 is for improving adhesion with DFR. UT-4120 is for improving adhesion with Solder mask.



異方性エッチング処理

Anisotropic etching treatment

We enhance the accuracy of fine wire patterning.

7ブライト ECBRITE

EXE series

塩化銅エッチャント向け10%添加剤タイプです。 通常の塩化銅エッチャントよりも高いEFを得ることができます。 エッチング後の配線幅ばらつきを抑制することができます。 10% additive type for copper chloride etchant. Higher etching factor compared to conventional copper chloride etchant. Variation in pattern width after etching can be suppressed.











Evaluation board size 410 \times 510 mm Copper thickness:23 $\mu \rm m$ DF thickness :25 $\mu \rm m$



We have applied to surface treatment the technologies of selective metal etching and copper microetching that were cultivated in metal resist stripping, enabling us to meet a wide range of needs.



メックのエッチング液での 最大エッチング速度 Maximum etching rate with MEC's etchant

	Al	Zn	Fe	Co	Ni	Sn	In	Bi	Cu	Pd	W	Мо	cIT0	N iC r (Cr20%)	SUS304
エッチング速度 Etching rate	0.77	123.6	17.4	16.7	17.0	57.7	164.5	39.1	31.2	0.57	0.034	0.77	0.12	12.1	15.7
µm/min															

選択エッチング性 Selective etching characteristics

メックのエッチング液での取り除きたい金属と保護したい金属の組み合わせ表 Combination table of metals to be removed and metals to be protected with MEC's etchant



処理可能(保護対象はエッチングしない)エッチング対象は100nm/min以上 Possible (Protection target does not etching) Etching rate : over 100nm/min

処理可能(保護対象はエッチングしない)エッチング対象は10~100nm/min Possible (Protection target does not etching) Etching rate : 10~100nm/min

A	処理可能(エッチング速度比 10倍以上) Possible (Etching rate more than 10 times)
В	処理可能(その他) Possible (Other)
無印 No mark	不可 Impossible

エッチング対象金属(取り除きたい) Metals for etching

		Al	Zn	Fe	Co	Ni	Sn	In	Bi	Cu	Pd	W	Mo	cIT0	NiCr (Cr20%)	SUS304
保護対象金属(残したい	Al		A	A	S	A	A	S	A	S		S	S			
	Zn	A												Partie		
	Fe	S	A		S		В	S	S	S		S	S			
	Co	A	A	Α			Α	A, S		S		S	S			
家金屋	Ni	S	Α	S	A		A	A	S	S		S	S			
低。	Sn	A			S			S		S		S	S			
1 1 1-	In	A	Α		Α	В	Α			S						
	Bi	A	Α		S		В	S		S		S	S			
保護したい)	Cu		Α		Α	A	Α	Α		\geq					В	
〔〕 た	Pd	S	S	S	S	S	S	S	S	S	\geq	S	S		Α	A
	W	S	S	S	S	S	S	S	S	S	S		S	S	S	S
	Мо	S	A	A	A	A	Α	A	A, S	Α					Α	A
tals t	Ag	S	S	S	S	S	S	S	S	S		S	S			
o be i	Pt	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
remai	Au	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
Metals to be remained or protected	Si	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
r prot	Ti	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
ected	Та	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
	Nb	S	S	S	S	S	S	S	S	S	S	S	S	S	S	S
	cITO	S	S	S	S	S	S	S	S	S	S	S	S		S	S
	NiCr (Cr20%)	S	S	S	S	S	S	S	S	S	S	S	S			
	SUS304	S	S	S	S	S	S	S	S	S	S	S	S			

部材の構成によっては対応できない場合があります。SUS304とSUS316、SUS430は同様の傾向です。 Some combinations may not be compatible, depending on the type of elements on the boards. SUS304 and SUS316, SUS430 are similar trends. 選択エッチング

Selective etching



銅パターンをほとんど侵すことなく、絶縁樹脂表面に付着しているパラジウム 触媒残渣を除去します。 PJ-9720 removes palladium catalyst residue adhered to insulating resin surfaces with nearly no copper pattern corrosion.



Optimally designed microetching agents for all types of processes and applications.

ソルダーレジスト前処理 Pre-treatment for solder resist

ドライフィルム前処理 Pre-treatment for DFR 少ないエッチング量で銅表面に独特の粗化形状を形成する硫酸-過酸化

メックブライト

水素系マイクロエッチング剤です。ド

ライフィルムラミネート前やソルダーレジスト形成前に適しており、密着性を 向上させる効果があります。銅溶解量が多く、過酸化水素の安定性に優れて いるため、ランニングコストを低減できます。 CB-5004 is a sulfuric acid-hydrogen peroxide based microetching agent that forms a unique roughened topography on copper surfaces, even with a low etching amount. It is suitable for processes prior to dry film lamination and solder resist formation, and improves the adhesion. The process can reduce the running costs because of the excellent hydrogen peroxide stability and the high copper capacity.



小径穴断線低減

ベックブライト MECBRITE SF-5420

CB-5004

弱アルカリ性のマイクロエッチング剤です。スルーホール断線の危険性を低減します。HALや耐熱 性プリフラックスなどの最終仕上げ前処理として、また銅ーはんだ共存基板の処理にも適しています。 SF-5420 is an alkalescent microetching agent that reduces the risk of through-hole disconnection. It is suitable as a pretreatment for HAL and thermal resistant OSP finishing, as well as in treatment of copper-solder multi-metal PWBs.

汎用タイプ General-purpose typ メックブライト MECBRITE

CA-91Y, CB-801Y, CB-5602AY

硫酸–過酸化水素系のマイクロエッチング剤です。銅表面の酸化物を除去すると共に、 表面を活性化させます。HALや耐熱性プリフラックスなどの最終仕上げ前、ドライフィ ルムラミネート前など、各種工程の前処理としてご使用ください。 This series consists of sulfuric acid-hydrogen peroxide based microetching agents. The agents remove oxides from copper surfaces, while also re-activating the surfaces. Use these agents to perform a pretreatment for HAL and thermal resistant OSP finishing, dry film lamination, and other processes.

銅の除錆、防錆 Anti-tarnish / Rust removal

銅表面保護に幅広く対応し、 品質の向上を実現します。

Improving quality through wide-ranging copper surface protection.

脱脂 メックブラ Degreasing		銅および金属表面上に付着した指紋等 の油分や酸化物の汚れを速やかに除去 する酸性脱脂剤です。	CA-5302 is an acidic degreasing agent that quickly removes contaminants such as fingerprint oils and oxides adhered to copper and metal surfaces.			
脱脂 メックブラ Degreasing		銅表面の錆や指紋、酸化物・有機物の汚 率的に除去する弱アルカリ性の表面処理 This series is a mildly alkaline chemical that effective fingerprints, oxide, rust and organic matter on coppe	里剤です。 ely removes adhesives of dry fims as well as			
AOI検査前処理 Pre-treatment for AOI		[Organic acid type] 良品との区別を明確	することで、誤判定を防ぎます。良品と不 確にし、検査作業の効率と精度を高めます。			
	CAU-5220	L 伽酸糸」 [Sulfuric acid type]	correct measurements when used before AOI the efficiency and accuracy of inspection work g between good and defective products.			

各種残渣除去 residue removal

Effectively remove residues including resist and adhesive.



積層前処理

Pre-treatment for lamination

Environmentally-favored products developed as alternatives to black oxide treatment. The process is controlled automatically.





Reducing copper foil thickness and improving the accuracy of fine wire patterning.

HE-7002A

大量の銅を溶解するエッチダウン工程に適した硫酸-過酸化水素系のエッチング剤です。基板の表層銅を半分あるいはそれ以上薄くする場合にご使用ください。特に細線パターン形成を行う基板の前処理に最適です。適したエッチダウンをシステムでご提案します。

エッチダウン

Etch down

This series consists of sulfuric acid-hydrogen peroxide based etching agents suitable for etch down processes that dissolve large amounts of copper. Use the agents when thinning the copper layer by half or more. These agents are especially useful in the pretreatment of boards that form fine wiring patterns.





Copper surface treatment for CO₂ Laser Direct Drilling

We offer a complete lineup of chemical agents for optimizing the finishing of copper surfaces in CO₂ direct laser processes.

ダイレクトレーザ前処理 Pre-treatment for laser direct drilling

クレボンド

BO-7790V

硫酸-過酸化水素系マイクロエッチング剤です。

使用するダイレクトレーザのエネルギー吸収率を上昇させる表面形状を 創ります。 BO-7790V is a sulfuric acid-hydrogen peroxide based microetching agent. It creates a surface topography that increases the energy absorption rate during direct laser process.

ダイレクトレーザ後処理 Post-treatment for laser direct drilling

メックパワーエッ MEC PowerETCH HE-7002A

CO 2レーザを用いるダイレクトレーザ加工時に発生した銅の飛び散りやバリ を効率よく除去するマイクロエッチング剤です。 HE-7002A is a microetching agent that efficiently removes copper splashes and burrs generated during direct laser processing using a CO_2 laser.



Uyemura's Mission is creating and delivering practical solutions to the competitive, operational and environmental challenges our customers face.

UHDI is the industry's future. And in semiconductors, IC substrates and advanced microelectronics, MEC has developed and proved processes that are needed now by the mainstream PWB industry.

It's time. And MEC from Uyemura is Already There.

UYEMURA

Global Leader in Final Finishes, Specialists in Solutions for High Density and Ultra-High Density Circuits

UYEMURA Corporate Headquarters:

3990 Concours, #425 Ontario, CA 91764 ph: (909) 466-5635

UYEMURA Tech Center:

240 Town Line Road, Southington, CT 06489 ph: (860) 793-4011

uyemura.com